

(19)



JAPANESE PATENT OFFICE

PATENT ABSTRACTS OF JAPAN

(11) Publication number: 2003191420 A

(43) Date of publication of application: 08.07.03

(51) Int. Cl

B32B 27/36

B05D 5/12

C08J 7/04

// C08L 67:00

(21) Application number: 2001400263

(71) Applicant: MITSUBISHI POLYESTER FILM
COPP

(22) Date of filing: 28.12.01

(72) Inventor: HAYASHIZAKI KEIICHI

(54) ANTISTATIC FILM

electrophotographic materials, magnetic recording
materials, and cards, etc.

(57) Abstract:

PROBLEM TO BE SOLVED: To provide an antistatic polyester film which can coat an antistatic film at a low processing cost, has excellent transparency, antistatic properties and regenerability, and is useful for packing materials, plate making materials, printing materials, graphic materials, photosensitive materials,

SOLUTION: The antistatic film has a coating layer containing a compound which has two or more quaternary nitrogens in a molecule and the counter anion of which is a nitrate ion on one surface of the polyester film.

COPYRIGHT: (C)2003,JPO